



## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant

Edward Y. CHANG

Confirmation No: 4041

Appl. No.

: 10/699,839

Filed

: November 4, 2003

Title : GROWTH OF Ga

: GROWTH OF GaAs EPITAXIAL LAYERS ON SI SUBSTRATE

BY USING A NOVEL GeSi BUFFER LAYER

TC/A.U.

: 2818

Examiner

: M. C. Tran

Docket No.:

: CHAN3228/REF

Customer No:

: 23364

## **AMENDMENT**

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

This is in response to the Official Action of June 20, 2005, in connection with the above-identified application. This response is timely filed.

Please amend the application as follows:

Amendments to the claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 5 of this paper.